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Notice of Allowability	Application No.	Applicant(s)
	10/681,553	BERGMAN, ERIC J.
	Examiner	Art Unit
	Michael Kornakov	1746
The MAILING DATE of this communication appears on the cover sheet with the correspondence address All claims being allowable, PROSECUTION ON THE MERITS IS (OR REMAINS) CLOSED in this application. If not included herewith (or previously mailed), a Notice of Allowance (PTOL-85) or other appropriate communication will be mailed in due course. THIS NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIGHTS. This application is subject to withdrawal from issue at the initiative of the Office or upon petition by the applicant. See 37 CFR 1.313 and MPEP 1308.		
1. This communication is responsive to <u>06/21/2004</u> .		
2. The allowed claim(s) is/are <u>1-12, 14-16, 21-23</u> .		
3. 🗵 The drawings filed on <u>07 October 2003</u> are accepted by the Examiner.		
 4.		
Attachment(s) 1. ☑ Notice of References Cited (PTO-892) 2. ☐ Notice of Draftperson's Patent Drawing Review (PTO-948) 3. ☑ Information Disclosure Statements (PTO-1449 or PTO/SB/0 Paper No./Mail Date 6/21/04,10/07/03, 7/27/04 4. ☐ Examiner's Comment Regarding Requirement for Deposit of Biological Material	6. ☐ Interview Summary (Paper No./Mail Date 8), 7. ☐ Examiner's Amendm	e

Application/Control Number: 10/681,553

Art Unit: 1746

REASONS FOR ALLOWANCE

The following is an examiner's statement of reasons for allowance: The instant claims recite cleaning a semiconductor substrate, utilizing the steps of introducing a water based heated liquid onto the rotating semiconductor substrates and introducing ozone gas and carbon dioxide gas into the chamber to clean semiconductor substrate. The closest prior art of record are EP 0548596 and US 5,632,847 to Ohno et al.

EP'596 teaches application ozone gas to rotating substrate, while the substrate being sprayed with ultra pure water. The teaching of EP'596 does not anticipate or suggest fairly the step of introduction a carbon dioxide gas and the step of applying ultra pure water, wherein the water is heated within the temperature range as instantly claimed.

Ohno et al teach a method of removing contaminants from a semiconductor substrate including the steps of injecting ozone into aqueous acid solution and bringing ozone bubbles to the substrate surface to remove contaminants. The teaching of Ohno et al does not anticipate or suggest fairly the step of introducing a carbon dioxide gas into the processing chamber during the cleaning operation. The aqueous solution of Ohno et al is maintained at a room temperature, which is well below the instantly claimed temperature range.

No other prior art that anticipates or suggests fairly the cleaning process with the combination of steps as instantly claimed has been located as of the date of this office action. Therefore, claims 1-12, 14-16, 21-23 are allowed over the prior art of record.

Art Unit: 1746

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Michael Kornakov whose telephone number is (571) 272-1303. The examiner can normally be reached on 9:00am - 5:30pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Michael Barr can be reached on (571) 272-1414. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

M. KORNAKON

Michael Kornakov Primary Examiner Art Unit 1746

08/20/2003